User guide for the Test Sample Generator (ver. 2.1) program

Type of Measurement	Patterns	Dye Parameters	Acquisition Paramet	ers
Polarization sensitive	axons ^	Dye 1 Dye	2 Frame size (px):	64
Dual-Colour	vesicies	Select dye: Alexa Fluor 647	Number of frames:	3000
Crosstalk: 0; 0			65 Frame rate (1/s):	20
Astigmatic 3D	~		05 Exp. time (s):	0.05
Cylindrical I. f. (m): 10				160
Magnification: 100	Modify Delete	Char. OFF time (s): 4	1.6 Pixel size (nm):	
Tube lens f. (cm): 20	Add New Pattern	Bleaching constant (s): 17	Av. BG level:	200
Fix seed for rand. numbers		Emitted photon/sec: 104	1000 Struct. BG strength:	0
The seed for rand. numbers	Import from parameters file	Mean bonding angle (°):	0 RI of immersion m.:	1.518
PSF Type		SD of bonding angle (*):	RI of sample m.:	1.331
Gaussian		Mean N of labels/epitope:	1 Numerical aperture:	1.4
O Scalar			0 Electrons/count:	21.5
O Vectorial				2.5
Gaussian PSF Parameters				90
Opt. coll. eff.: 0.3		Non-spec. I. dens. (1/um3):	0 Actual EM gain:	
			Quantum efficiency:	0.9
	Drift Pa	ameters		
	Drift type: No drift 🗸	Std of acc (nm/s): 0 0	0	
	Drift velocity (nm/s): 0 0 0	Damping coeffs (1/s, 1/nm): 0		Plot label
ave As				
		Search Export parame	ters Import parameters	Generat

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First steps

TestSTORM is written in Mathworks Matlab to generate simulations for Single Molecule Localization Microscopy (SMLM). The source code is distributed under the GPLv3 license and can be freely downloaded from the website: http://titan.physx.u-szeged.hu/~adoptim/?page_id=183

To start TestSTORM, extract the contents of the downloaded file. Open Mathworks Matlab and navigate to the extracted folder. Run the **testSTORM.m** file (F9).

Detailed description

The minimum requirement for TestSTORM v2.1 is Mathworks Matlab R2014a.

Note: We recommend a dual-core computer with minimum 4GB of RAM.

"Type of Measurement" panel

Type of Measurement Polarization sensitive			
Dual-Colour			
Crosstalk:	0; 0		
Astigmatic 3D			
Cylindrical I. f (m):	10		
Magnification:	100		
Tube lens f. (cm):	20		
Fix seed for rand. numbers			

There are several measurement simulation modes implemented in TestSTORM v2.1. These can be selected in the "Type of Measurement" panel and can be used in any combination.

Polarization sensitive simulation creates two image stacks with "_polX" and "_polY" attached to their file names. In this simulation mode only the vectorial PSF model can be used. The two generated stacks contain the PSFs created by the X and Y linearly polarized light components incident on the detector.

In the *Dual-Colour* simulation mode, the structures are labelled with two different type of dyes. The blinking events of the two dyes appear in two separate image stacks with "_dye1" and "_dye2" attached to their file names. The intensity of the *Crosstalk*

between the two image stacks can also be set, e.g. "0; 0.1" means that the blinking events of the first dye appear only in the first image stack while the blinking events of the second dye appear both in the first and in the second image stacks with a photon number ratio of 1:9. The labelling densities of the two dyes can be set among the parameters of each pattern in the field devoted for the epitope density or for the epitope number. By default, only one value is given in these fields, which means, that the labelling densities for the two dyes are considered equal. Different labelling densities can be given for the two dyes with two values separated with semicolon in the epitope density or epitope number field of the given pattern.

The **Astigmatic 3D** simulation mode introduces a controlled amount of astigmatism to the PSFs. The size and shape of the distorted PSF depends on the axial position of the emitter. The magnitude of astigmatism is calculated from the focal length of the tube lens (**Tube lens f.**), from the focal length of the cylindrical lens (**Cylindrical I. f.**) causing the astigmatism and from the **Magnification** of the objective.

For the reproducibility of the measurement simulations, "fix seed" mode can be enabled for random number generation (*Fix seed for rand. numbers*). When fix seed mode is used, simulations with the same parameters yield exactly the same image stacks. Otherwise, the structures of "random" patterns distributed randomly in the active area, the distribution of the dye molecules is random on the structures, the number of dye molecules and the sequence of blinking events may vary from simulation to simulation even if exactly the same parameters were used.

"PSF Type" panel

- Gaussian
- ◯ Vectorial

In TestSTORM v2.1 the user can choose from different PSF models. These PSF models require significantly different computational power depending on the model complexity and should be selected according to the actual problem.

Gaussian PSF model

The Gaussian PSF model assumes that the intensity distribution and the axial dependence of the PSF width match those of a Gaussian beam. The optical collection efficiency (*Opt. coll. eff.*) describes the portion of the emitted photon flux which can be collected by the

microscope system and imaged onto the surface of the detector. This parameter is determined by the total transmittance of the system and the numerical aperture (NA) of the microscope objective. Its typical value is between 0.3-0.4 in case of an oil immersion objective with high numerical aperture. This PSF model is by far the least demanding in computational power and should be used when the simulated structure is near the focal plane and the fluorophores have high rotational mobility.

Scalar PSF model

The scalar PSF model employed in TestSTORM is based on the Gibson and Lanni PSF model¹ (with the addition of the apodization and transmission terms), which accounts for the aberration caused by the stratified medium and has asymmetric PSF size dependence on the axial position. This model requires the object distance from the objective's aperture

under design conditions (*Focal plane d.*) and the thickness of the sample medium between the focal plane and the cover slip (*Sample depth*).

Vectorial PSF model

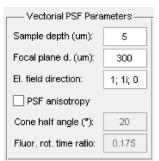
The vectorial PSF model is based on the Richards and Wolf PSF model² and is useful for simulating fixed dipoles. In addition to the *Focal plane distance* and the *Sample depth*, it requires the polarization vector of the exciting field (*El. field direction*). It can also account for the PSF anisotropy³ that can be set via the ratio between the fluorescence and the rotational correlation time (*Fluor. rot. time ratio*), and the *Cone half angle*, which defines the cone within the dipole can freely rotate. The computational cost of the vectorial PSF model is about twice, while that of the PSF anisotropy calculation is more than six times higher than that of the scalar PSF model.

LIMITATIONS:

Setting the numerical aperture higher than 1.4 with the scalar or with the vectorial PSF models is not recommended. These PSF models include a term describing the transmission coefficients of rays with different angles. In case of simulating with water sample layer and with immersion oil using very high numerical aperture (NA>1.4), the calculated transmission coefficients of the outer rays are very low, so these models predict no advantage with a numerical aperture that high. Moreover, in this case the focal position approximation algorithm cannot find the position of minimal PSF size well enough. If you want to use very high numerical aperture values, consider using a PSF model which does not include the term of the transmission coefficients. These other PSF models can be selected in the code (/functions/m_gen_aperture_func.m), but this feature is not exposed to the GUI. If you have trouble setting them, please contact us! It is also possible to test the size and the shape of the generated PSFs with the test_TestSTORM_PSF.m function.

Sample depth (um):	5
Focal plane d. (um):	300
the focal plane a	and the

Scalar PSF Parameters



— Gaussian PSF Parameters —				
Opt. coll. eff.:	0.3			

"Patterns" panel

Modify	Delete
Add Nev	w Pattern
Import from p	arameters file

The user can add new structures to the simulation, modify or delete existing ones, or import the structures from an external file containing the parameters of a previous simulation.

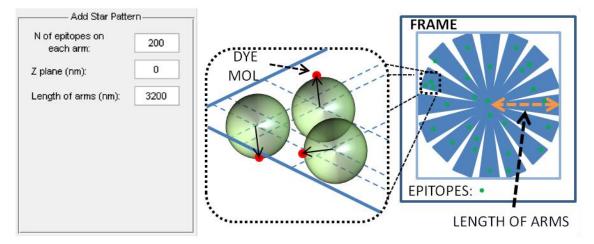
When adding a new pattern, the user can choose from eight types of predefined and from two types of

arbitrary patterns with different geometrical parameters. In the star pattern the molecules form a star with 16 arms within the frame. In the array pattern the molecules are linked to points forming a matrix. The vesicles pattern consists of labelled sphere surfaces. In case of the lines pattern five fixed lines are labelled. In the octagon pattern the molecules are placed on the vertices of octagons. In the axon pattern the molecules are distributed on equidistantly placed circles on cylindrical surfaces, while in the disks pattern the molecules are placed upon equidistantly placed disk pairs. The rods pattern comprises tubes with hemispherical caps at their ends. The two arbitrary patterns are segmented lines and triangular mesh surfaces. These patterns cannot be created within TestSTORM but can be imported from external files.

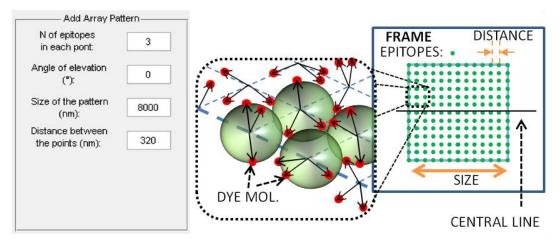
Star Pattern
Array Pattern
Vesicles Pattern
Rods Pattern
C Lines Pattern
Octagons Pattern
Axons Pattern
Disks Pattern
Read Lines from File
Read Mesh from File
ok

Available patterns

Star: This pattern forms a centred star on the frame with 16 arms. The epitopes are randomly distributed on the surface of each arm. The number of the epitopes located on the arms (*N of epitopes on each arm*), the *Length of arms* and the plane of the pattern in Z direction (*Z plane*) can be set (the focal plane corresponds to z=0 nm). In this pattern the labels are located on the surfaces of spheres that are placed around each epitope on the arms. The labelling density follows normal distribution on a sphere whose mean bonding angle and bonding angle variance are determined by the input parameters of the dye. The linkers are then rotated uniformly around the surface normal in order to make the distribution rotationally symmetric and the linkers are randomly mirrored to the arm surface to obtain reflection symmetry.



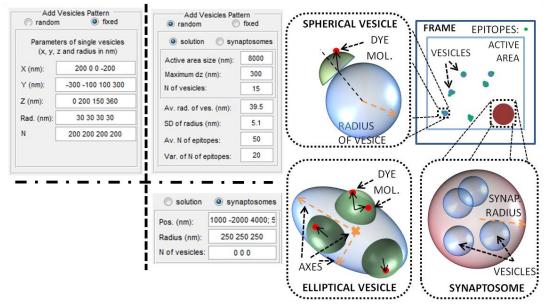
Array: This pattern is a centred grid on the frame. The linkers are located on the points of the grid. The number of epitopes located on one lattice point (*N of epitopes in each point*), the angle between the focal plane and the plane of the pattern (*Angle of elevation*) is variable (the central line of the pattern is located in the focal plane). The *Distance between the points* of the grid and the *Size of the pattern* can also be modified by the user. In this pattern the labels are located on the surfaces of spheres that are placed around each epitope. The linker orientation probability follows uniform distribution.



Vesicles: This pattern consists of labelled spheres. The position of the centres of the modelled vesicles can be defined by the user or can be randomly distributed within an active area. By default, the vesicles have spherical shapes, but ellipsoidal vesicles with three different axes can also be defined. In the later case, the first two axes are parallel with the focal plane, while the third axis is parallel with the optical axis. Otherwise, the orientation of the ellipsoid is random. The ellipsoidal vesicles might be useful for simulating e. g. the shells of bacterial spores. In this pattern, the labels are randomly put on the surface of half spheres around the epitopes located on the outer vesicle surfaces. The linkers are then rotated uniformly around the surface normal in order to make the distribution rotationally symmetric.

In the random vesicles pattern, the vesicles can be distributed uniformly in the solution region defined by a rectangular cuboid volume or within synaptosomes defined by spherical volumes. The input parameters belonging to the solution region of the sample are: the number of vesicles in the solution (*N of vesicles*), the *Active area size*, the maximum distance between the centre of the vesicles and the focal plane in axial direction (*Maximum dz*). The synaptosomes are defined by their positions (*Pos.*, the X, Y and Z positions must be separated with semicolons), radii (*Radius*) and the number of vesicles within them (*N of vesicles*). In the random vesicles pattern the vesicles cannot overlap. If the algorithm is not able to fit any more vesicles in a synaptosome or in the solution region without overlapping, it simply does not place anymore and fewer vesicles will be defined, than the number given by the user. The other input variables are: the average radius of vesicles (*Av. rad. of ves.*), the standard deviation of the radius of vesicles (*SD of radius*), the average number of epitopes placed on the vesicles (*Var. of N of epitopes*). The radii of vesicles follow normal, while the number of epitopes placed on them follows binomial distribution.

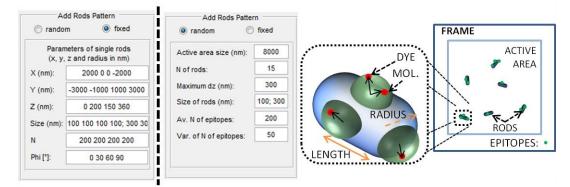
The input parameters in the case of a fixed sample: lateral (X, Y) and axial (Z) coordinates of the centres, the radii of each vesicle (*Rad.*) and the number of epitopes (N) placed on them.



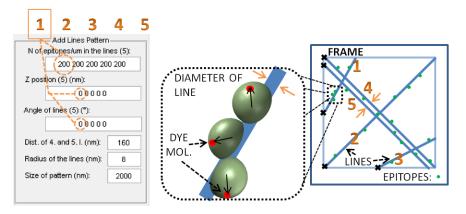
Rods: The rods pattern comprises cylindrical surfaces with hemispherical caps at their ends. The axis of the cylindrical tubes are parallel with the focal plane, otherwise the rods' orientation are random. This pattern might be useful for simulating e. g. the shells of bacterial spores. In this pattern, the labels are randomly placed on the surface of hemispheres around the epitopes located on the outer surfaces of the rods. The linker orientation probability follows normal distribution on a sphere whose mean bonding angle and bonding angle variance are determined by the input parameters of the dye. The linkers are then rotated uniformly around the surface normal in order to make the distribution rotationally symmetric.

The input parameters in case of random sample are: the number of rods (*N of rods*), the *Active area size*, the maximum distance between the centre of the vesicles and the focal plane in axial direction (*Maximum dz*), the radii of the caps and tubes and the length of the tubes of each rod (*Size of rods*, these two kind of values must be separated with a semicolon), the average number of epitopes placed on the rods (*Av. N of epitopes*) and the variance of the number of epitopes placed on the rods (*Var. of N of epitopes*). The number of epitopes placed on the rods follows binomial distribution.

The input parameters in the case of a fixed sample: lateral (*X*, *Y*) and axial (*Z*) coordinates of the centres, the radii of the caps and tubes and the length of the tubes of each rod (*Size* field, these two kind of values must be separated with a semicolon), the number of epitopes (*N*) placed on them, and the azimuth angles of the tubes' axes.



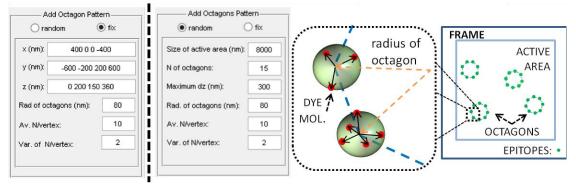
Lines: This pattern consists of five stained lines with fixed position. The contact points of linkers are randomly distributed along each line. The following parameters can be modified by the user: the epitope density (*N of epitopes/µm on the lines*), the *Z position* of the starting point of each line (signed by "x" in the figure), the elevation *Angle of the lines* and the *Size of pattern*. The *Radius of the lines* gives the radii of cylindrical surfaces on which the contact points are placed. The distance between the two parallel lines (*Dist. of 4. and 5. l.*) is also variable. In this pattern the labels are located on the surfaces of hemispheres around the epitopes placed on the outer side of the cylindrical surfaces along the lines. The linker orientation probability follows normal distribution on a sphere whose mean bonding angle and bonding angle variance are determined by the input parameters of the dye. The peak of the bonding angle distribution lies in the plane determined by the axis of the cylindrical surface and the surface normal vector at the actual epitope.



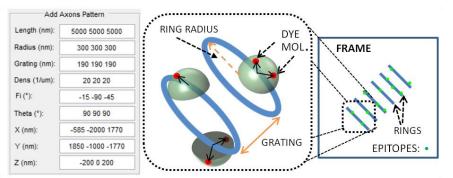
Octagons: This pattern consists of octagons labelled at their vertices. This pattern is aimed to model nuclear pore complexes (NPCs). The positions of the centres of octagons can be defined by the user or randomly distributed within an active area. In this pattern the labels are located on the surfaces of spheres that are placed around the contact points on each vertex. The linker orientation probability follows uniform distribution.

The input parameters in case of random sample are: the octagon radius (*Rad. of the octagons*) and number (*N of octagons*), the average number of epitopes placed on the vertices (*Av. N/vertex*), the variance of the number of epitopes on the vertices (*Var. of N/vertex*), the *Size of active area* and the maximum distance between the centre of the octagons and the focal plane along the optical axis (Z direction). The radius of vesicles and the number of molecules linked to one octagon follows binomial distribution.

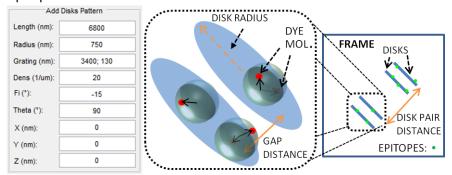
The input parameters in the case of a fixed sample are: *X*, *Y* and *Z* coordinates of the centres, the radius (*Rad. of the octagons*), the average number of epitopes placed on the vertices (*Av. N/vertex*) and the variance of the number of epitopes on the vertices (*Var. of N/vertex*).



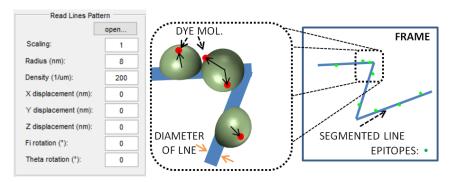
Axons: This pattern models axon segments, where the epitopes are bonded to the outer surfaces of equidistantly placed rings. The possible positions of the molecules form hemispheres. It is possible to define one or several segments. The *Length* of the segments, the *Radii* of their rings, the distance of adjacent rings (*Grating*), the linear density of the epitopes on rings (*Dens*), the polar (*Theta*) and the azimuth (*Fi*) angles of the axes and central positions (*X*, *Y*, *Z*) can be set individually for each segment. In this pattern the labels are located on the surfaces of hemispheres around the epitopes placed on the outer side of the cylindrical surfaces determined by the rings. The linker orientation probability follows normal distribution on a sphere whose mean bonding angle and bonding angle variance are determined by the input parameters of the dye. The peak of the distribution lies in the plane determined by the actual ring.



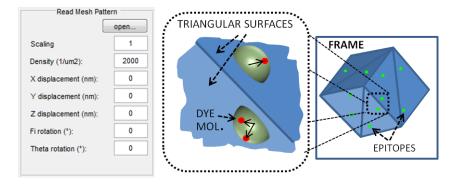
Disk: The disks pattern comprises parallel disk pairs distributed along the given line segments and the disk pairs are placed equidistantly along them. This pattern might be useful for modelling the Z-discs of striated muscle fibers. The **Length** of the segments, the **Radii** of the disks, the gap between the disks forming the pairs and the distance of the disk pairs (**Grating**, these two kind of values must be separated with a semicolon), the linear density of the epitopes on rings (**Dens**), the azimuth (**Theta**) and the polar (**Fi**) orientations of the axes and central positions (**X**, **Y**, **Z**) can be defined individually for each segment. In this pattern the labels are located uniformly on the surfaces of spheres centred around each epitope on the disks.



Read Lines Pattern: Using this mode the user can import a pattern of segmented lines from an external file. This file can be created with the JFilament ImageJ plugin⁴. Although it can contain several segmented lines, only the same *Radius* and epitope *Density* can be set for them. Some affine transformations, namely scaling, translation (*X displacement, Y displacement, Z displacement*), rotation around the *Y axis* (*Fi rotation*) and rotation around the Z axis (*Theta rotation*), can be performed on the pattern, and they are executed in the mentioned order. In this pattern the labels are located on the surfaces of hemispheres centred around each epitope on the cylindrical surfaces along the lines. The linker orientation probability follows normal distribution on a sphere whose mean bonding angle and bonding angle variance are determined by the input parameters of the dye. The peak of the distribution lies in the plane determined by the axis of the cylindrical surface and the surface normal vector at the actual epitope.



Read Mesh Pattern: Using this mode ASCII *.stl files containing a triangular mesh can be imported and can form arbitrary surfaces. The epitope **Density** on the triangular surfaces can be set. Some affine transformations, namely scaling, translation (*X displacement, Y displacement, Z displacement*), rotation around the Y axis (*Fi rotation*) and rotation around the Z axis (*Theta rotation*), can be performed on the pattern, and they are executed in the mentioned order. In this pattern the labels are located on the surfaces of hemispheres centred around each epitope on the triangles (on the outer side if the input *.stl file contains surface normal, otherwise, they are placed on both sides randomly). The linker orientation probability follows normal distribution on a sphere whose mean bonding angle and bonding angle variance are determined by the input parameters of the dye. The linkers are then rotated uniformly around the surface normal in order to make the distribution rotationally symmetric.



"Dye Parameters" panel

Dye Parameters	
Dye 1) Dye 2
Select dye: Alexa Fluo	r 647 🗸
Emission WL (nm):	665
Char. ON time (s):	0.05
Char. OFF time (s):	41.6
Bleaching constant (s):	1700
Emitted photon/sec:	104000
Mean bonding angle (°):	0
SD of bonding angle (°):	30
Mean N of labels/epitope:	1
Var. N of labels/epitope:	0
Length of linkers (nm):	7
Non-spec. I. dens. (1/um3):	0

These parameters describe the general properties of the dye molecules. In the labelling model used in TestSTORM v2.0, point-like epitopes are placed on the surfaces of structures, and the dye molecules are attached to these contact points. The number of dye molecules connected to epitopes follows binomial distribution with a mean value given by *Mean N of labels/epitope* and with a variance given by Var. N of labels/epitope. The Length of linker parameter gives the distance between the contact point and the dye molecule (e.g. the size of the antibody). With the exception of patterns comprising point-like structures, the bonding angles (the angle between the linker and the pattern surface normal) follow normal distribution on a sphere characterized by its mean (Mean bonding angle) and standard deviation (SD of bonding angle) values. Three constants determine the behaviour of the dye molecules in time: the characteristic time constant of ON (Char ON time), OFF (Char. OFF time) and bleached state (Bleaching constant). They define the probabilities of the transmission between the states. The emission wavelength (Emission WL) is the central wavelength of the emission spectra. The *Emitted photon/sec* parameter means the total number of photons emitted in a second from a fluorescent dye molecule in active state. The non-specific label density (Non-spec. I. dens.) determines the density of randomly placed labels in a

20 Rayleigh length thick region.

"Drift Parameters" panel

The drift panel contains the parameters required for simulating the drift trajectory. Although the user can choose from predefined drifts in the *Drift type* field, the parameters describing the drift can be freely changed. The drift trajectory is modelled with the movement of a point mass in a damping medium affected by random forces as the following formula describes:

$$r_{n+1} = r_n + v_n \Delta t - (b - c|v_n - v^{mean}|) \frac{(v_n - v^{mean})\Delta t^2}{2} + \frac{a_n^{rand}\Delta t^2}{2},$$

where r_n , v_n , a_n^{rand} are the drift trajectory, the velocity and the acceleration caused by the random force belonging to the *n*th frame respectively, v^{mean} is the mean drift velocity, Δt is the full frame time, *b* and *c* are the linear and square drag coefficients. The three components of the standard deviation of the random acceleration's distribution, the mean drift velocity and the linear and square damping coefficients can be set in **Std of acc**, **Drift velocity** and **Damping coeffs** fields, respectively.

			Drift I	Parameters	
Drift type:	Mediu	ım	\sim	Std of acc (nm/s):	330
Drift velocity (nm/s):	0.5 0	5 0	Damping coeffs (1/s, 1/nm):	0.1 0.2

"Acquisition Parameters" panel

Acquisition Parameters		
Frame size (px):	64	
Number of frames:	3000	
Frame rate (1/s):	20	
Exp. time (s):	0.05	
Pixel size (nm):	160	
Av. BG level:	200	
Struct. BG strength:	0	
RI of immersion m.:	1.518	
RI of sample m.:	1.331	
Numerical aperture:	1.4	
Electrons/count:	21.5	
Pre-amplification:	2.5	
Actual EM gain:	90	
Quantum efficiency:	0.9	

The "Acquisition parameters" panel encompasses the main parameters of the camera and of the optical system required for creating the image stack. Frame size is the number of pixels in X and Y directions. Number of frames is the length of the simulated sequence. Frame rate describes the number of frames that can be acquired during a second. The exposure time (*Exp. time*) is the time when the detector is capturing photons (full frame time - readout time). The *Pixel size* is the size of a pixel measured in the focal space of the objective (real pixel size of the camera divided by the magnification of the imaging system).

There are two background types in TestSTORM. The first gives the average values of pixels on a captured blank frame and is described by the Av. BG level field. The second type, the structured background strength (Struct. BG. strength), is related to the sample and can be characterized with one value or with two values separated with a space or a comma, giving the constant or the starting and the ending levels of this kind of background. If two values are used, the structured background changes in a linear way between the two levels.

The *Numerical aperture* and the refractive index of the sample medium (*RI of sample* **m**.) are used for predicting or determining the PSF spot size. The refractive index of the immersion medium (RI of immersion m.) is required for the scalar and for the vectorial PSF models or when astigmatic 3D simulation mode is used.

The incoming photon-count conversion of the camera is calculated in the following way: the product of the incoming photon number calculated from the emitted photon/s, optical collection efficiency, the actual lifetime of the active state, the Pre-amplification, the actual electron multiplying gain (Actual EM gain) and the Quantum efficiency of the camera is divided by the *Electrons/count* rate. Most of these parameters can be found in camera manuals. Poisson noise is also added to each pixel.

"Save as" panel

The generated image stack can be saved in **TIF** or **RAW** format. The destination and the filename can be given by clicking on the "Search" button. A data file is also provided with columns: frame index, index of the active molecule, X, Y and Z coordinates of the molecules in nm and the number of captured photons.

– Save As	
	Search

Other Buttons

Plot labels

The "Plot labels" button plots the positions of the labels in a 3D figure. If two types of dyes are used, the first and the second dye will be depicted with red and green colours, respectively.



The "Recalculate" button changes the seed for the random number generation, thus the position of all randomly placed structures, the number and position of the labels will be recalculated. It can be used only if the "Fix seed for rand. numbers" is disabled in the "Type of Measurement" panel.



Hitting the Generate button starts the simulation and generates the image stack(s) containing the blinking events, which are written out to disk at the end. The data file containing the molecule positions and the blinking events' properties is also written out to the disk at the end of the simulation.

Export parameters

Import parameters

With the "Export parameters" button the user can save the current simulation parameters into a *.mat file. With the "Import parameters" button the user can import the parameters of a previous simulation from a *.mat file.

Generating the sample

The "testSTORM.m" first adds the required folders to the search path by running "startup.m", then opens the GUI and handles the button calls.

By clicking on the "**Plot labels**" button, the parameters describing the different given structures are generated with "m_gen_calc_struct_coords.m". Then the coordinates of dye molecules attached to structures and of the nonspecific labels are calculated. Eventually the dye coordinates are plotted in a 3D figure.

The "**Generate**" button's call function calculates the dye coordinates the same way as the "Plot labels" button's if no plotting has been performed previously, or recalculates them if the input parameters have changed since the last plotting. Afterwards the "m_gen_combine_dyes.m" combines the non-specific labels and the labels bonded to structures into a single array. Then "m_gen_traj_gen.m" generates temporal trajectories for each molecule using the defined characteristic times. After that "m_gen_trajs_to_seq.m" produces the frame stacks containing the blinking events considering the acquisition parameters and molecule temporal trajectories. The "m_gen_noise_addition.m" function adds Poisson noise to the frame sequence and finally the "m_gen_seq_save.m" routine saves the frame stack in the appropriate file format.

Additional tools

The **script** folder contains separate test versions of some functions used by the program.

test_m_gen_trajs_drift.m plots the drift trajectory and one can check the applied drift.

m_gen_PSF_numerical_calc subfolder contains tools for visualizing the intensity distributions of the scalar and the vectorial PSF models.

Additional information

- Tibor Novák, Tamás Gajdos, József Sinkó, Gábor Szabó and Miklós Erdélyi: TestSTORM: Versatile simulator software for multimodal super-resolution localization fluorescence microscopy, *Sci.Rep.*, doi: 10.1038/s41598-017-01122-7 (2017)
- Erdélyi, M., Sinkó, J., Gajdos, T., Novák T. Enhanced simulator software for image validation and interpretation for multimodal localization super-resolution fluorescence microscopy. *Proc. SPIE*, doi:10.1117/12.2250116 (2017).
- Sinkó, J. et. al. TestSTORM: Simulator for optimizing sample labeling and image acquisition in localization based super-resolution microscopy, *Biomed. Optics Express* **5**, 778-787 (2014).

If you have any questions, reflections or suggestions, please, do not hesitate to contact Dr. Miklos Erdelyi (<u>meerdelyi@gmail.com</u>). Please, refer our paper if you use this program in your work.

References

- 1. Gibson, S. F., Lanni, E. Experimental test of an analytical model of aberration in an oil-immersion objective lens used in three-dimensional light microscopy. *J. Opt. Soc. Am. A.* **9**, 154-66 (1992).
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